

## Refine Search

### Search Results -

Terms	Documents
6162587.pn.	2

Database:

US Pre-Grant Publication Full-Text Database  
 US Patents Full-Text Database  
 US OCR Full-Text Database  
 EPO Abstracts Database  
 JPO Abstracts Database  
 Derwent World Patents Index  
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Search:

L5





### Search History

DATE: Thursday, March 10, 2005    [Printable Copy](#)    [Create Case](#)

<u>Set</u> <u>Name</u> side by side	<u>Query</u>	<u>Hit</u> <u>Count</u>	<u>Set</u> <u>Name</u> result set
<i>DB=PGPB,USPT,USOC,EPAB,JPAB,DWPI,TDBD; PLUR=YES; OP=ADJ</i>			
<u>L5</u>	6162587.pn.	2	<u>L5</u>
<u>L4</u>	L3 and silicon nitride	4	<u>L4</u>
<u>L3</u>	L1 and (hardmask same first photoresist same second photoresist same trench)	4	<u>L3</u>
<u>L2</u>	L1 and (hardmask same (remov\$ near3 first photoresist) same second photoresist same trench)	0	<u>L2</u>
<u>L1</u>	438/\$.ccls.	167583	<u>L1</u>

END OF SEARCH HISTORY